



## 11th International SAOT Workshop on Laser Based Micromanufacturing



Foto: K. Cvecek

## Workshop Programme

Monday, January 10	
8.30 am – 9.00 am	Reception
9.00 am – 9.15 am	Opening Remarks  M. Schmidt, University of Erlangen Nuremberg, Germany
9.15 am – 10.05 am	3D Metamaterials and Plasmonic Structures H. Giessen, University of Stuttgart, Germany
10.05 am – 10.20 am	Coffee break
10.20 am – 11.10 am	RF Metamaterials  M. Wiltshire, Imperial College London, Great Britain
11.10 am – 12.00 pm	From THz to X-rays: Unconventional Approaches to Study Laser Micro-machining  T. Ozaki, University of Québec, Canada
12.00 pm – 12.55 pm	Lunch
12.55 pm – 1.45 pm	<i>TBA</i> <u>S. Nolte,</u> University of Jena, Germany
1.45 pm – 2.35 pm	Surface Engineering by Laser Ablation and Modification A. Ostendorf, Ruhr-Universität Bochum, Germany
2.35 pm – 2.50 pm	Coffee break
2.50 pm – 3.40 pm	Optical Near Fields of Nano-objects: Characterization and Surface Structuring P. Leiderer, University of Konstanz, Germany
3.40 pm – 4.30 pm	Application of Ultrafast Lasers for Modern Photonic Technologies  I. Alexeev, University of Erlangen-Nuremberg, Germany

Evening Programme		
5.50 pm	Bus to Nuremberg leaves at Unicum	
6.00 pm	Bus to Nuremberg leaves at Hotel Altmannstube	
6.30 pm	Guided tour in the historic centre of Nuremberg (*)	
8.00 pm	Dinner at the Albrecht-Dürer-Stube in Nuremberg (*)	

<sup>(\*)</sup> Applications are welcome (only restricted attendance possible)



Guided tour through Nuremberg city at night with the "Lebküchnerin" and dinner at the Albrecht-Dürer-Stube.

Tuesday, January 11		
8.30 am – 9.20 am	Laser Processing and Chemistry: Applications in Nano- patterning, Material Synthesis and Biotechnology D. Bäuerle, University of Linz, Austria	
9.20 am -10.10 am	Femtosecond Laser Nanoprocessing and Plasmonics: Fundamentals and Biomedical Applications M. Meunier, École Polytechnique de Montréal, Canada	
10.10 am – 10.25 am	Coffee break	
10.25 am – 11.15 am	Nanophotonics with Two Photon Polymerization and Laser Induced Transfer  B. N. Chichkov, Leibniz Universität Hannover, Germany	
11.15 am – 12.05 pm	Three-dimensional Diffraction-unlimited Direct-laser-writing Optical Lithography M. Wegener, Karlsruhe Institute of Technology, Germany	
12.05 pm – 1.00 pm	Lunch	
1.00 pm – 1.50 pm	Materials Issues in Micromanufacturing with Emphasis on Laser-based Additive Manufacturing <u>D. Bourell</u> , University of Texas, USA	
1.50 pm – 2.40 pm	Integrated Approach to Study Selective Laser Melting: Parametric Analysis, Modelling, Optical Diagnostics I. Smurov, École Nationale d'Ingénieurs de Saint-Etienne, France	
2.40 pm – 2.55 pm	Coffee break	
3.15 pm – 4.15 pm	Lab Tour at LPT and blz	
4.15 pm	End of Workshop	